Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	4	"20030082466" or "6059507".pn.	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/11/20 07:54
L2	629485	(\$5lithograph\$2 or (expos\$3 or imag\$3 or pattern\$3) near5 (wafer or substrate or workpiece))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/11/20 09:05
L3	15389	(load near2 lock or loadlock)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/11/20 08:23
L4	4187	(handler or robot or arm or transporter or convey\$3 hand or loader or carrier) with projection near2 (system or unit or apparatus or device)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/11/20 08:25
L5	161	(handler or robot or arm or transporter or convey\$3 hand or loader or carrier) with projection near2 chamber	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/11/20 08:25
L6	4314	(4 or 5)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/11/20 09:04
L7	887330	(two or dual or plural or multiple) near4 (hold\$3 or support\$3 or stage or chuck)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/11/20 08:27
L8	2554335	(positioning or align\$4)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/11/20 09:10

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L9	200323	((increas\$3 or decreas\$3) near3 distance or rais\$3 or lower\$3) with (upper or ceiling) near2 (plate or support\$3 or hold\$3 or chuck) with (lower near2 (plate or support\$3 or hold\$3) or plate or support\$3 or hold\$3)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/11/20 08:38
L10	48984	((increas\$3 or decreas\$3) near3 distance or rais\$3 or lower\$3) with first with second near4 (plate or support\$3 or hold\$3 or chuck)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/11/20 08:39
L11	614	3 same 7	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/11/20 08:40
L12	66	3 with (9 or 10)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/11/20 09:01
L13	1057	3 with 8	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/11/20 09:04
L15	196	13 and 11	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/11/20 08:42
L16	28	13 and 12	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/11/20 08:42
L17	22	15 and 16	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/11/20 08:43

L18	3	3 with (9 or 10) with (vacuum or negative near2 pressure)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/11/20 09:03
L19	2	3 with (9 or 10) with (evacuat\$3 or vacuum or negative near2 pressure).clm.	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/11/20 09:03
L20	172	3 with 8.clm.	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/11/20 09:04
L21	563	(4 or 5).clm.	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/11/20 09:04
L22	105037	(\$5lithograph\$2 or (expos\$3 or imag\$3 or pattern\$3) near5 (wafer or substrate or workpiece)).clm.	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/11/20 09:06
L23	2	20 and 21 and 22	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/11/20 09:06
L24	0	(positioning or align\$4) with (decreas\$3 or reduc\$4 or lower\$3) near3 gas near2 volume near4 (object or wafer or substrate or workpiece).clm.	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/11/20 09:11
L25	257	355/53,72,75.ccls. and @pd>"20070730"	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/11/20 09:27

L26	32	414/217.ccls. and @pd>"20070730"	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT;	OR	ON	2007/11/20 09:29
			IBM_TDB			